

**Amendments to the Specification:**

Please replace the paragraph beginning on page 1, line 15, with the following rewritten paragraph:

As an alternative to the dip dyeing method, there has been proposed a vapor deposition dyeing method, which is for example disclosed in U.S. Patent No. 6,520,999 (Japanese patent unexamined publication No. 2001-59950). This method includes heating a sublimatable dye under vacuum to sublimate the dye and vapor deposit the sublimed dye onto a lens ~~which is heated simultaneously under vacuum~~, thereby dyeing the lens. According to this vapor deposition dyeing method, a lens made of a material hard to dye by the conventional dip dyeing method can also be dyed and additionally working conditions can extremely be improved.